

**REMARKS**

**Election Requirement**

The Examiner has required Applicants to elect one of the following patentably distinct species of the invention:

Species I. illustrated in Figure 7;

Species II. illustrated in Figure 10; or,

Species III. illustrated in Figure 11.

Applicants hereby elect Species II, illustrated in Figure 10 and believe that claims 1-13 are readable on the elected species.

**Claim Amendments**

Claims 8-13 have been amended to properly depend from independent claim 7.

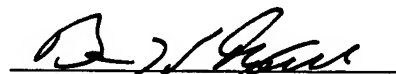
**Summary**

An early action on the merits of this application is respectfully requested. Should any points remain in issue, which the Examiner feels could best be resolved by either a personal or a telephone interview, it is urged that Applicants' local attorney be contacted at the exchange listed below.

Respectfully submitted,

Date: February 3, 2003

By:

  
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**VERSION WITH MARKINGS TO SHOW CHANGES MADE**

**IN THE CLAIMS:**

Claims 8-13 have been amended as follows:

--8. (Amended) The method of Claim [1] Z, wherein a size of said contact hole pattern is larger than a size of said independent spot pattern.

9. (Amended) The method of Claim [1] Z, wherein sizes and shapes of said independent spot patterns can be adjusted to control roughness degrees of said pixel electrode.

10. (Amended) The method of Claim [1] Z, wherein sizes and shapes of said independent spot patterns can be adjusted to control roughness degrees of said photosensitive passivation layer.

11. (Amended) The method of Claim [1] Z, wherein said independent spot patterns are defined by forming hollow areas on said mask.

12. (Amended) The method of Claim [1] Z, wherein said independent sport patterns are defined by forming the covering area on said mask with chromium films.

13. (Amended) The method of Claim [1] Z, wherein a first distance between two adjacent said independent spot patterns is smaller than a resolution of an exposure system while a second distance between adjacent said independent spot pattern and said contact hole pattern is larger than said resolution of said exposure system.--

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